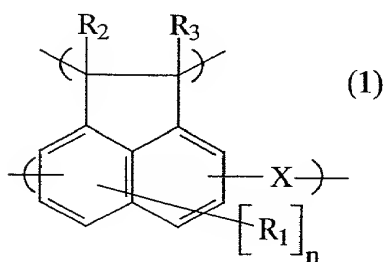


ABSTRACT OF THE DISCLOSURE

An anti-reflection coating-forming composition is provided. This composition includes a polymer and a solvent. The polymer
 5 has a structural unit represented by the formula (1):



wherein R_1 is a monovalent atom other than a hydrogen atom or a monovalent group, and n is an integer of 0-4, provided that when
 10 n is an integer of 2-4, a plural number of R_1 's are the same or different; R_2 and R_3 are each a monovalent atom or group; and X is a bivalent group. The anti-reflection coating formed from this composition has a high antireflective effect, does not
 15 generate intermixing with a resist film, and enables a good resist pattern profile excellent in resolution and precision in cooperation with a positive or negative resist.